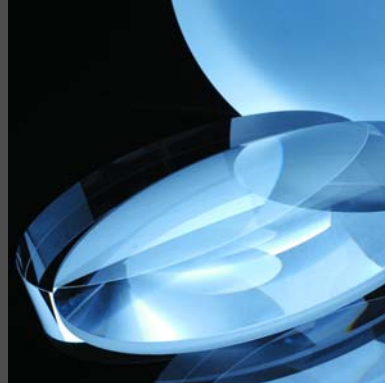


HPFS® Fused Silica KrF Grade



CORNING
Discovering Beyond Imagination



Semiconductor
Optics

HPFS® KrF Grade, Corning code 7980, is a high purity synthetic amorphous silicon dioxide manufactured by flame hydrolysis. The noncrystalline, colorless, silica glass combines a very low thermal expansion coefficient with excellent optical qualities and exceptional transmittance in the deep ultraviolet. KrF Grade was developed for 248 nm lithography systems.

In order to satisfy the challenging quality requirements of our customers in leading edge applications such as microlithography, Corning is dedicated to continuous improvement. Our investments in research and development, combined with Corning's quality systems, support our technology leadership position and ensure that we meet our customer's requirements on time, every time.

Quality Grade Selection Chart — HPFS® KrF Grade

Corning defines and certifies the quality of HPFS® glass using two criteria: inclusions and homogeneity grade.

Inclusion Class			Homogeneity ^{3,4} ppm			
			Grade			
Class	Total Inclusion ¹ Cross Section [mm ²]	Maximum ² Size [mm]	AA ≤ 0.5	A ≤ 1	C ≤ 2	F ≤ 5
0	≤ 0.03	0.10	■	■	■	■
1	≤ 0.10	0.28		■	■	■
2	≤ 0.25	0.50			■	■

NOTES:

1. Defines the sum of the cross section in mm² of inclusions per 100 cm³ of glass. Inclusions with a diameter ≤ 0.10 mm are disregarded.
2. Refers to the diameter of the largest single inclusion.
3. Index homogeneity: the maximum index variation (relative), measured over the clear aperture of the blank.
4. Index homogeneity is certified using an interferometer at 632.8 nm. The numerical homogeneity is reported as the average through the piece thickness. Blanks with a diameter up to 450 mm can be analyzed over the full aperture. Larger parts can be analyzed using multiple overlapping apertures. The minimum thickness for index homogeneity verification is 20 mm. For thinner parts, the parent piece is certified.

Mechanical and Thermal Properties:

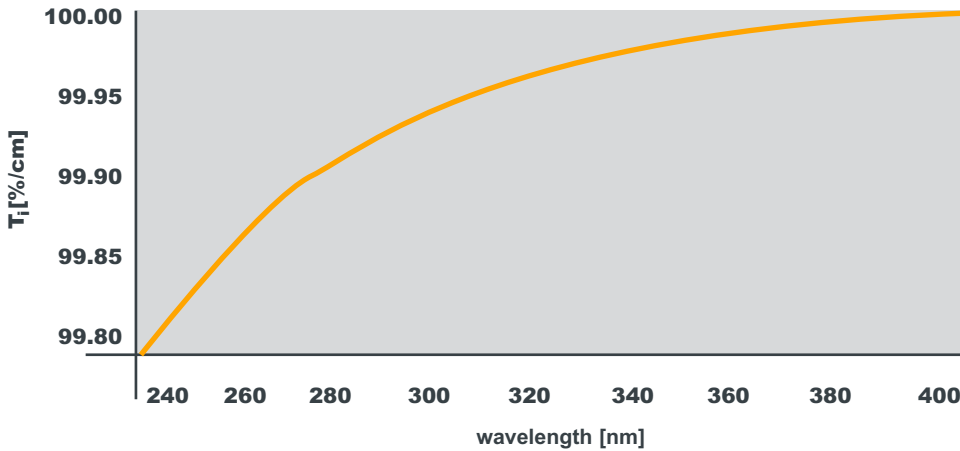
Unless otherwise stated, all values @ 25 °C

Elastic (Young's) Modulus	72.7 GPa	Softening Point	1585 °C (10 ^{7.6} poises)
Shear Modulus	31.4 GPa	Annealing Point	1042 °C (10 ¹³ poises)
Modulus of Rupture, abraded	52.4 MPa	Strain Point	893 °C (10 ^{14.5} poises)
Bulk Modulus	35.4 GPa	Thermal Conductivity	1.30 W/m K
Poisson's Ratio	0.16	Thermal Diffusivity	0.0075 cm ² /s
Density	2.201 g/cm ³	Average C.T.E.	0.52 ppm/K 5°C-35 °C
Knoop Hardness (100 g load)	522 kg/mm ²		0.57 ppm/K 0°C-200 °C
			0.48 ppm/K -100°C-200 °C

Chemical Durability and Impurities

Solution	Time	Weight Loss [mg/cm ²]	Impurities
5% HCL by weight @95 °C	24 h	<0.010	OH content (by weight): 800-1000 ppm Impurities other than OH: ≤ 500 ppb
5% NaOH @95 °C	6 h	0.453	
0.02N NA ₂ CO ₃ @95 °C	6 h	0.065	
0.02N H ₂ SO ₄ @95 °C	24 h	<0.010	
Deionized H ₂ O @95 °C	24 h	0.015	
10% HF by weight @25 °C	20 m	0.230	
10% NH ₄ F*HF by weight @25 °C	20 m	0.220	

Internal Transmittance: Code 7980 KrF Grade



HPFS® KrF Grade is certified to meet T_i ≥ 99.8%/cm@248nm when measured through a polished, uncoated sample. A typical internal transmittance curve for HPFS® KrF Grade fused silica is shown here.

Refractive Index and Dispersion

Data in 22°C in 760mm Hg dry nitrogen gas

Wavelength [air] λ [nm]	Refractive Index ^{*2} n	Thermal Coefficient $\Delta n/\Delta T$ ^{*3} (ppm/K)	Polynomial Dispersion Equation Constants ^{*1}	
			A ₀	A ₁
1128.64	1.448870	9.6	2.104025406	
1064.00	1.449633	9.6	-1.456000330 x 10 ⁻⁴	
1060.00	1.449681	9.6	-9.049135390 x 10 ⁻³	
1013.98 n _t	1.450245	9.6	8.801830992 x 10 ⁻³	
852.11 n _s	1.452469	9.7	8.435237228 x 10 ⁻⁵	
706.52 n _r	1.455149	9.9	1.681656789 x 10 ⁻⁶	
656.27 n _c	1.456370	9.9	-1.675425449 x 10 ⁻⁸	
643.85 n _{c'}	1.456707	10.0	8.326602461 x 10 ⁻¹⁰	
632.80 n _{He-Ne}	1.457021	10.0		
589.29 n _D	1.458406	10.1	Sellmeier Dispersion Equation Constants ^{*2}	
587.56 n _d	1.458467	10.1	B ₁	0.68374049400
546.07 n _e	1.460082	10.2	B ₂	0.42032361300
486.13 n _F	1.463132	10.4	B ₃	0.58502748000
479.99 n _{F'}	1.463509	10.4	C ₁	0.00460352869
435.83 n _g	1.466701	10.6	C ₂	0.01339688560
404.66 n _h	1.469628	10.8	C ₃	64.49327320000
365.01 n _i	1.474555	11.2		
334.15	1.479785	11.6		
312.57	1.484514	12.0	$\Delta n/\Delta T$ Dispersion Equation Constants ^{*3}	
308.00	1.485663	12.1		
248.30	1.508433	14.2	C ₀	9.390590
248.00	1.508601	14.2	C ₁	0.235290
214.44	1.533789	17.0	C ₂	-1.318560 x 10 ⁻³
206.20	1.542741	18.1	C ₃	3.028870 x 10 ⁻⁴
194.17	1.559012	20.4		
193.40	1.560208	20.5		
193.00	1.560841	20.6	Other Optical Properties	
184.89	1.575131	22.7		
			v _d	67.79
			v _e	67.64
			n _F - n _C	0.006763
			n _{F'} - n _{C'}	0.006802
			Stress Coefficient	35.0 nm/cm MPa
			Striae	ISO 10110-4 Class 5/Thickness Direction
			Birefringence	≤ 1nm/cm, lower specifications available

*1 Polynomial Equation: $n^2 = A_0 + A_1 \lambda^4 + A_2 \lambda^2 + A_3 \lambda^{-2} + A_4 \lambda^{-4} + A_5 \lambda^{-6} + A_6 \lambda^{-8} + A_7 \lambda^{-10}$ with λ in μm

*2 Sellmeier Equation: $n^2 - 1 = B_1 \lambda^2/(\lambda^2 - C_1) + B_2 \lambda^2/(\lambda^2 - C_2) + B_3 \lambda^2/(\lambda^2 - C_3)$ with λ in μm

*3 $\Delta n/\Delta T$ Equation (20-25°C) = $C_0 + C_1 \lambda^2 + C_2 \lambda^4 + C_3 \lambda^6$ with λ in μm

Resistance to Laser Damage

Samples of HPFS® KrF Grade are regularly tested for induced absorption at Corning's Metrology Laboratory, Sullivan Park Research Center, to maintain the high standards to which Corning is committed.

We are here to help you specify the best product for your application. For further information, please contact:

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